

<b>Notice of References Cited</b>	Application/Control No. 09/902,340		Applicant(s)/Patent Under Reexamination CHOU ET AL.	
	Examiner Martin J Angebranndt		Art Unit 1756	Page 1 of 1

#### U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

#### FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	08-007219	01-1996	Japan	Inaba et al.	**
	O	05-004896	01-1993	Japan	Taniguchi et al.	**
	P					
	Q					
	R					
	S					
	T					

#### NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
*	U	Tsai et al., "Critical Review Characterization of diamondlike carbon films and thier application as overcoats on thin film media for Magnetic recording", J. Vac. Sci Technol. A Vol. 6(6) pp. 3287-3291.			
*	V	Dischler et al., "Infared and Raman Analysis of hydrogenated amorphous carbon films prepared by RF plasma deposition from ...", conference proceedings ISPC-7 Eindhoven, July 1985 (paper A-1-4)			
*	W	Robertson, "Amorphous Carbon", Advances in Physics Vol. 35 (4) pp. 317,319 (1985)			
*	X	Shimizu et al., "Microstructures of hydrogenated amorphous carbon films prepared by RF, ...CVD.", J. Non-Cryst. Sol. Vol. 114 pp. 196-198 (1989).			

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.